67-200-557 2001-0179

What is claimed is:

1. A cathode contact pin for making electrically conductive contact with a conductive area for carrying out an electrodeposition process comprising:

a stem region disposed adjacent a tip region said stem region for interfacing with an electrical source of power for carrying electrical power to said tip region said tip region having a radius of curvature forming a tip region contact surface for contacting a metal contact pad region such that upon contact a contacting portion of the tip region contact surface is confined within an area defined by the metal contact pad region.

- 2. The cathode contact pin of claim 1, wherein the stem region cross section comprises a round or polygonal shape.
- 3. The cathode contact pin of claim 1, wherein the stem region has an outer diameter that is within a range from about one half a tip region radius to about four times a tip region radius.

- 4. The cathode contact pin of claim 3, wherein a tapered transition region connects the stem region to the tip region.
- 5. The cathode contact pin of claim 1, wherein the radius of curvature along the tip region contact surface varies to form an ellipsoid shape.
- 6. The cathode contact pin of claim 1, wherein the metal contact pad region includes a rectangular area from about 50 microns to about 200 microns on a side.
- 7. The cathode contact pin of claim 1, wherein the stem region and tip region include at least one of aluminum, copper, palladium, nickel, gold, silver, rhodium and iridium.
- 8. The cathode contact pin of claim 1, wherein the metal contact pad region comprises a metal layer overlying at least an insulating layer.

- 9. The cathode contact pin of claim 7, wherein the at least an insulating layer includes a plurality of metal filled openings including at least one of vias and trench lines.
- 10. The cathode contact pin of claim 8, wherein the metal layer and the plurality of metal filled openings include copper or an alloy thereof.
- 11. A cathode contact pin for making electrically conductive contact with a conductive area on a semiconductor wafer surface for carrying out an electrodeposition process comprising:
  - a stem region adjacent a tip region said stem region for interfacing with an electrical source of power for carrying electrical power to said tip region said tip region having a radius of curvature forming a tip region contact surface for contacting a metal contact pad region disposed at the periphery of a semiconductor wafer said metal contact pad region including a metal layer overlying at least an insulating layer.

67-200-557 2001-0179

- 12. The cathode contact pin of claim 11, wherein the stem region adjacent the tip region has an outer diameter that is within a range from about one half a tip region radius to about four times a tip region radius.
- 13. The cathode contact pin of claim 12, wherein a tapered transition region connects the stem region to the tip region.
- 14. The cathode contact pin of claim 11, wherein the radius of curvature along the tip region contact surface varies to form an ellipsoid shape.
- 15. The cathode contact pin of claim 11, wherein the stem region cross section comprises at least one of a round or polygonal shape.
- 16. The cathode contact pin of claim 11, wherein the tip region has a radius of from about 50 microns to about 200 microns.

67-200-557 2001**-**0179

- 17. The cathode contact pin of claim 11, wherein the stem region and tip region include at least one of aluminum, copper, palladium, nickel, gold, silver, rhodium and iridium.
- 18. The cathode contact pin of claim 11, wherein the metal contact pad region is in electrical communication with a central portion of a semiconductor wafer including a metal seed layer.
- 19. The cathode contact pin of claim 11, wherein the at least an insulating layer includes a plurality of metal filled openings including at least one of vias and trench lines.
- 20. The cathode contact pin of claim 11, wherein the at least an insulating layer comprises a material with a dielectric constant of at most about 3.0.